

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of :
Ki-Hwan PARK et al. : Group Art Unit 1711
Application No. 10/695,770 : Examiner F. Stinson
Filed: October 30, 2003 : Confirmation No. 6935

METHOD OF AND APPARATUS FOR CLEANING SEMICONDUCTOR
WAFERS

AMENDMENT

U.S. Patent and Trademark Office
E-FILING
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

In response to the Office Action dated September 8, 2010, please amend the above-identified application according to the following:

Amendments to the Specification begins on page 2 of this paper.

Amendments to the Claims as reflected in the listing of claims which begins on page 3 of this paper.

Remarks/Arguments begin on page 10 of this paper.